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| SERIAL NUMBER | FILING DATE | FIRST NAMED APPLICANT | ATTORNEY DOCKETT NO. |
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| EXAMINER |
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| ART UNIT | PAPER NUMBER |
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DATE MAILED:

EXAMINER INTERVIEW SUMMARY RECORD

All participants (applicant, applicant's representative, PTO personnel):

(1) John Hoffmann (3) Ed Murphy
(2) Mike Goldman (4)

Date of interview 6-30-99

Type: ☐ Telephonic ☒ Personal (copy is given to ☐ applicant ☐ applicant's representative).

Exhibit shown or demonstration conducted: ☐ Yes ☒ No. If yes, brief description:

Agreement ☐ was reached with respect to some or all of the claims in question. ☒ was not reached.

Claims discussed: 7+17

Identification of prior art discussed: Kratel, Carpenter, Schwarz & Kawaguchi

Description of the general nature of what was agreed to if an agreement was reached, or any other comments: It was argued that the Schwarz reference produces silicic acid that is chemically & structurally different from the claimed material. Exr would consider was uncertain & will consider when amendment is filed. It was argued that the finality should be withdrawn.

(A fuller description, if necessary, and a copy of the amendments, if available, which the examiner agreed would render the claims allowable must be attached. Also, where no copy of the amendments which would render the claims allowable is available, a summary thereof must be attached.)

☒ 1. It is not necessary for applicant to provide a separate record of the substance of the interview.

Unless the paragraph below has been checked to indicate to the contrary, A FORMAL WRITTEN RESPONSE TO THE LAST OFFICE ACTION IS NOT WAIVED AND MUST INCLUDE THE SUBSTANCE OF THE INTERVIEW (e.g., items 1-7 on the reverse side of this form). If a response to the last Office action has already been filed, then applicant is given one month from this interview date to provide a statement of the substance of the interview.

☐ 2. Since the examiner's interview summary above (including any attachments) reflects a complete response to each of the objections, rejections and requirements that may be present in the last Office action, and since the claims are now allowable, this completed form is considered to fulfill the response requirements of the last Office action. Applicant is not relieved from providing a separate record of the substance of the interview unless box 1 above is also checked.

PROPOSED AMENDMENTS FOR INTERVIEW

In the Claims:

18-19
Please cancel claims 8-9, ~~14-15~~, 28-29, and 31-32.

Please amend claims 7 and 17 as follows:

7. In a method for making a non-porous body of high purity fused silica glass doped with at least one oxide dopant comprising the steps of:

(a) producing a gas stream containing a silicon-containing compound in vapor form capable of being converted through thermal decomposition with oxidation or flame hydrolysis to SiO_2 and a compound in vapor form capable of being converted through oxidation or flame hydrolysis to at least one member of the group consisting of P_2O_5 and a metal oxide which has a metallic component selected from Group IA, IB, IIA, IIB, IIIA, IIIB, IVA, IVB, VA, and the rare earth series of the Periodic Table;

(b) passing said gas stream into the flame of a combustion burner to form amorphous particles of fused SiO_2 doped with an oxide dopant;

(c) depositing said amorphous particles onto a support; and

(d) either essentially simultaneously with said deposition or subsequently thereto consolidating said deposit of amorphous particles into a non-porous body; the improvement comprising utilizing as said silicon-containing compound in vapor form a halide-free [polymethylsiloxane] polymethylcyclsiloxane, whereby no halide-containing vapors from said silicon-containing compound are emitted during the making of said non-porous body of high fused silica glass.

17. In a method for making optical waveguide fibers of high purity fused silica glass doped with an oxide dopant comprising the steps of:

(a) producing a gas stream containing a silicon-containing compound in vapor form capable of being converted through thermal decomposition with oxidation or flame hydrolysis to SiO_2 and a compound in vapor form capable of being converted through oxidation or flame hydrolysis to at least one member of the group consisting of P_2O_5 and a metal

oxide which has a metallic component selected from Group IA, IB, IIA, IIB, IIIA, IIIB, IVA, IVB, VA, and the rare earth series of the Periodic Table;

(b) passing said gas stream into the flame of a combustion burner to form amorphous particles of fused SiO_2 doped with an oxide dopant;

(c) depositing said amorphous particles onto a mandrel;

(d) consolidating said deposit of amorphous particles into a non-porous transparent glass body; and

(e) drawing waveguide fiber from said body; the improvement comprising utilizing as said silicon-containing compound in vapor form a halide-free [polymethylsiloxane] polymethylcyclsiloxane, whereby no halide-containing vapors from said silicon-containing compound are emitted during the making of said optical waveguide fibers.